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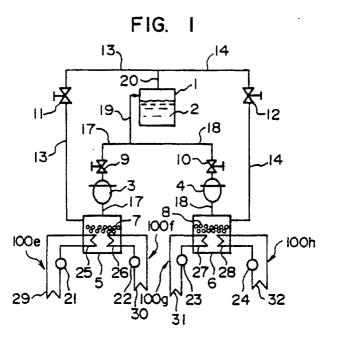
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- 4 Heat pump.
- A heat pump includes a reactor (5) adapted to accommodate a reaction material (7), the reactor (5) including a heat transfer device (100f) for accumulating heat and another heat transfer device (100e) for radiating heat. The reactor (5) communicates to a reservoir (1) adapted to accommodate a reaction

medium (2) through a heat accumulation pipe (17, 19) with a compressor (3) and a valve (9) and a heat radiation pipe (13) with a valve (11) to form a circulating loop. Heat pumps having such a construction may be arranged in parallel.





## EUROPEAN SEARCH REPORT

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	Citation of document with	n indication, where appropriate,	Re	levant	CLASSIFICATION OF THE
gory		rant passages	to	claim	APPLICATION (Int. Cl.5)
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					TECHNICAL FIELDS SEARCHED (Int. CI.5)
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	Place of search Date of completion of search				Examiner
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